



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

#  
16/w.m.  
2/23/01

In re application of

Hiroshi TAKANASHI et al.

Serial No. 09/262,077

Filed March 4, 1999

NEGATIVE-WORKING PHOTSENSITIVE  
RESIN COMPOSITION AND PHOTSENSITIVE  
RESIN PLATE USING THE SAME

Docket No. 01497/FP/TOK-16-US/YH

Group Art Unit 1752

Examiner S. Lee

THE COMMISSIONER IS AUTHORIZED  
TO CHARGE ANY DEFICIENCY IN THE  
FEES FOR THIS PAPER TO DEPOSIT  
ACCOUNT NO. 23-0975

PETITION FOR EXTENSION OF TIME

Assistant Commissioner for Patents  
Washington, DC 20231

Sir:

Petition hereby is made for a two month extension of time to respond to the communication of  
September 20, 2000.

The fee of \$390.00 is

- (X) submitted herewith.  
( ) to be charged to Deposit Account No. 23-0975. A duplicate copy of this Petition is enclosed.  
( ) Small entity status of this application is established by the verified statement under 37 CFR 1.9 and 1.27 which  
( ) is enclosed.  
( ) has been previously submitted.

Respectfully submitted,

Hiroshi TAKANASHI et al.

By

Matthew Jacob

Registration No. 25,154

Attorney for Applicants

02/21/2001 HVJUNG1 00000013 09262077

02 FC:116

390.00 OP

MJ/pjm  
Washington, D.C.  
Telephone (202) 721-8200  
February 20, 2001

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